PATENT APPLICATION

# **RESPONSE UNDER 37 CFR §1.116 EXPEDITED PROCEDURE TECHNOLOGY CENTER ART UNIT 3723**

#### IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Makoto KOBAYASHI et al.

Group Art Unit: 3723

Application No.:

09/830,434

Examiner:

H. Shakeri

Filed: April 26, 2001

Docket No.: 109352

For:

POLISHING PAD AND POLISHING METHOD FOR SEMI-CONDUCTOR WAFER

# TRANSMITTAL OF COURTESY COPY

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

TECHNOLOGY CENTER 3

Attached is a courtesy copy of an Amendment After Final Rejection that was filed on September 17, 2003 in the above-captioned patent application.

RECEIVED

SEP 2 3 2003

**TECHNOLOGY CENTER R3700** 

Respectfully submitted,

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WPB/CWB/JSA:amw

Date: September 22, 2003

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# **AMENDMENT AFTER FINAL REJECTION UNDER 37 CFR §1.116**

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In reply to the June 17, 2003 Office Action, please consider the following:

Amendments to the Claims as reflected in the listing of claims; and

Remarks.